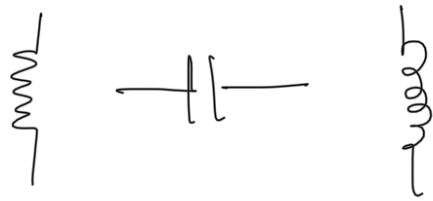
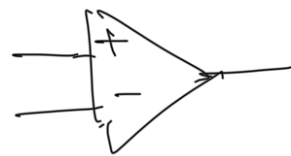
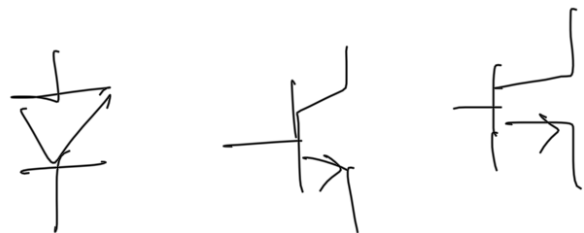


* Introduction

Basic Electric Components

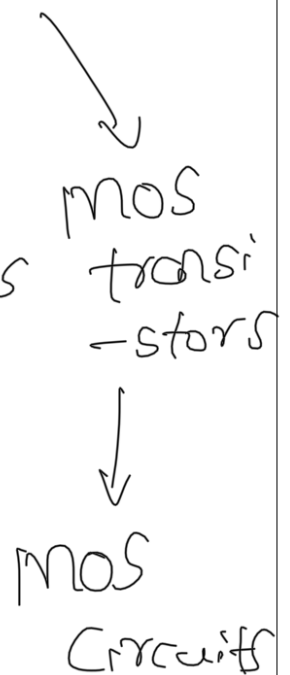
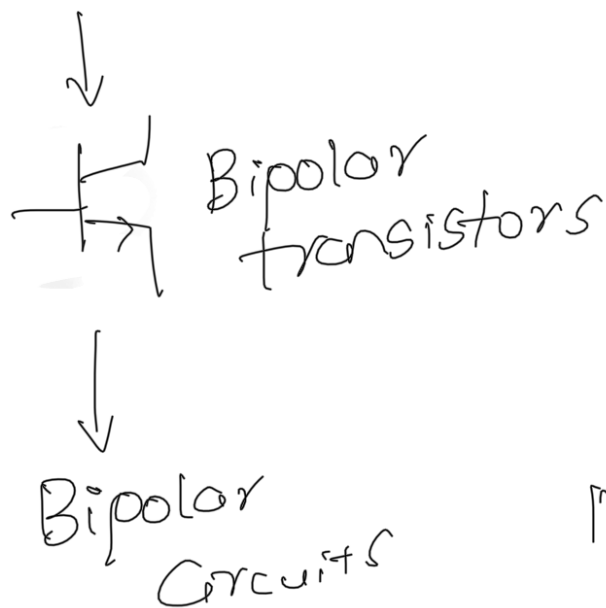
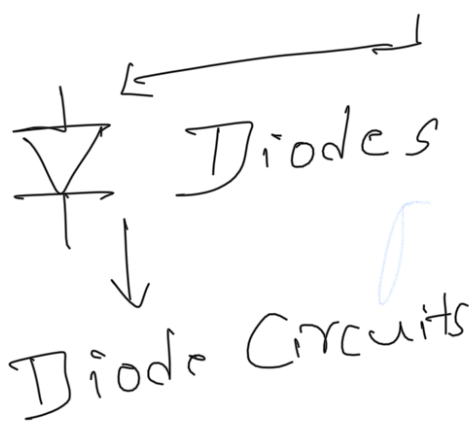


Electronics



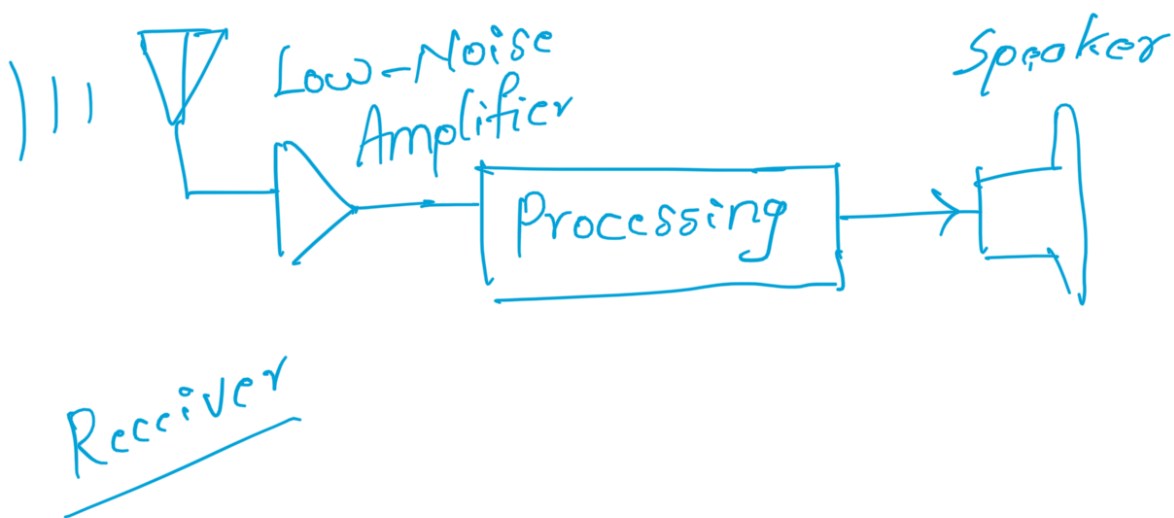
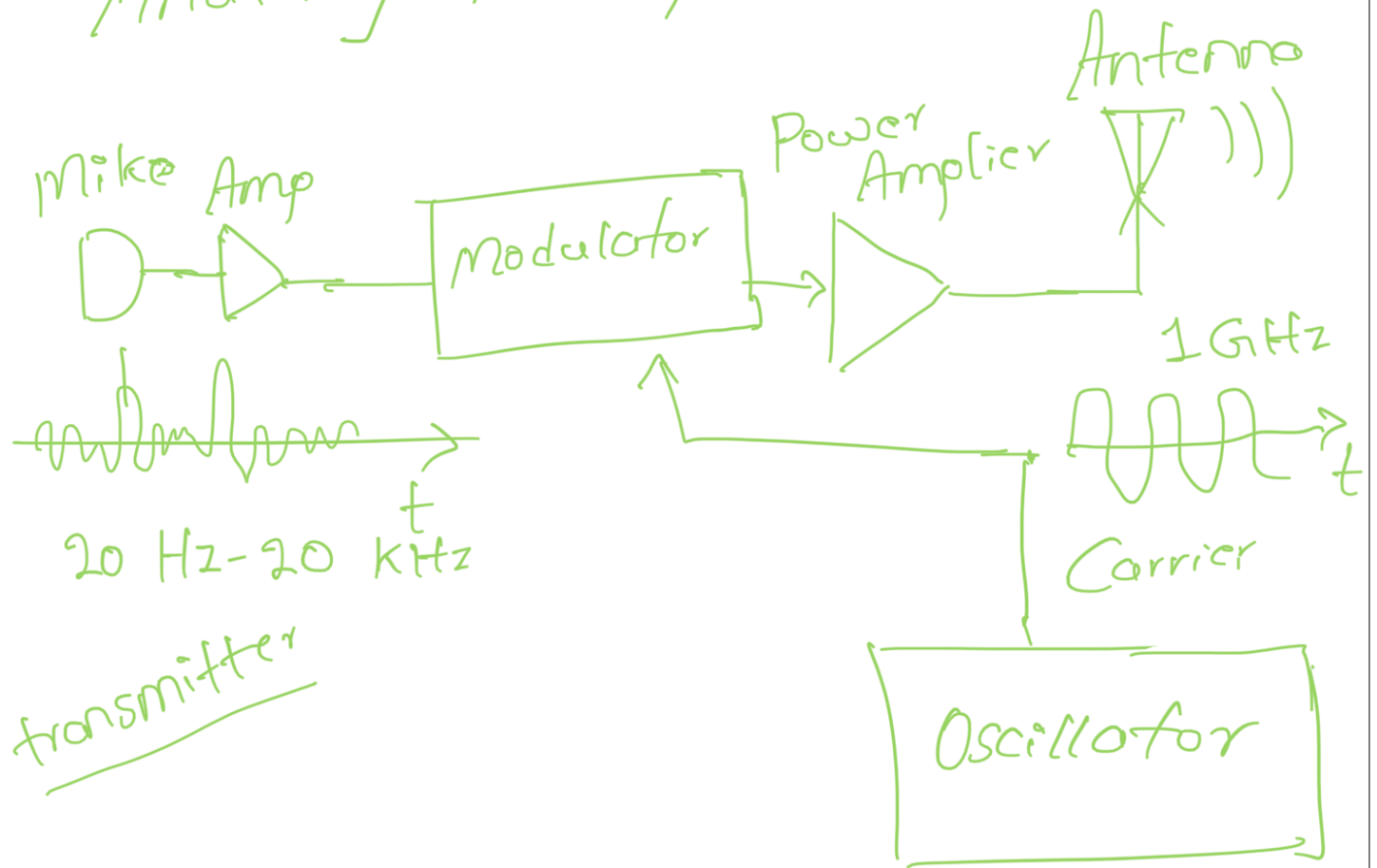
* Outline

Semiconductor Physics



Op-Amp based circuits

Anatomy of Cellphone



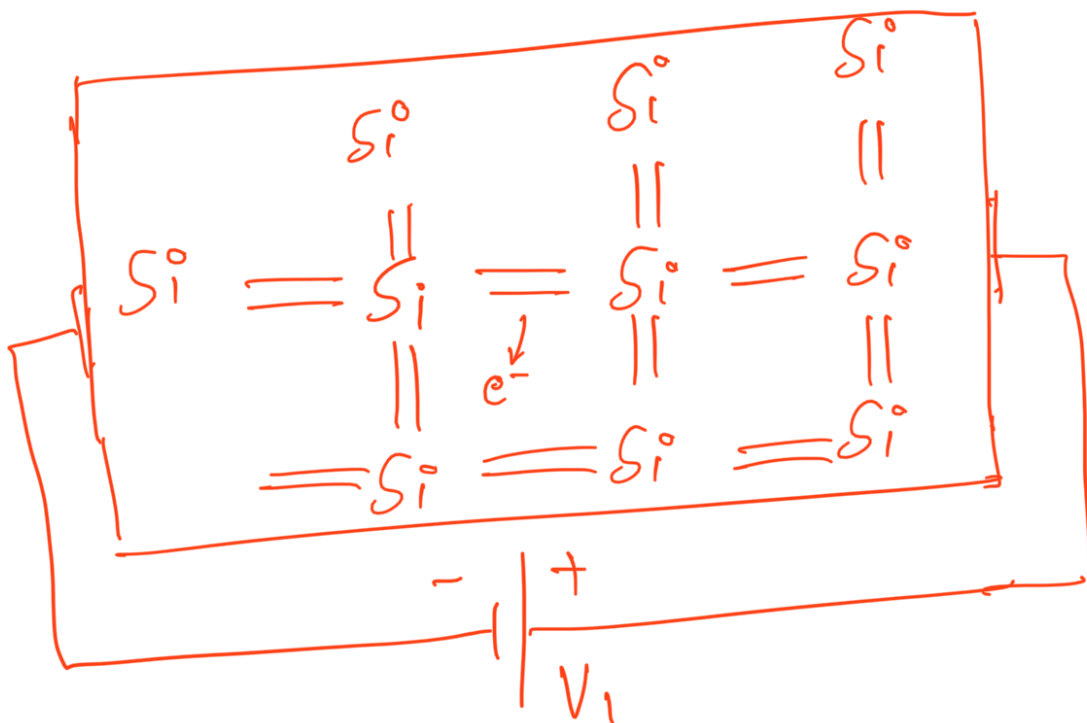
* General Concepts



Sodium : $1 e^-$

Neon : $8 e^-$

Silicon : $4 e^-$

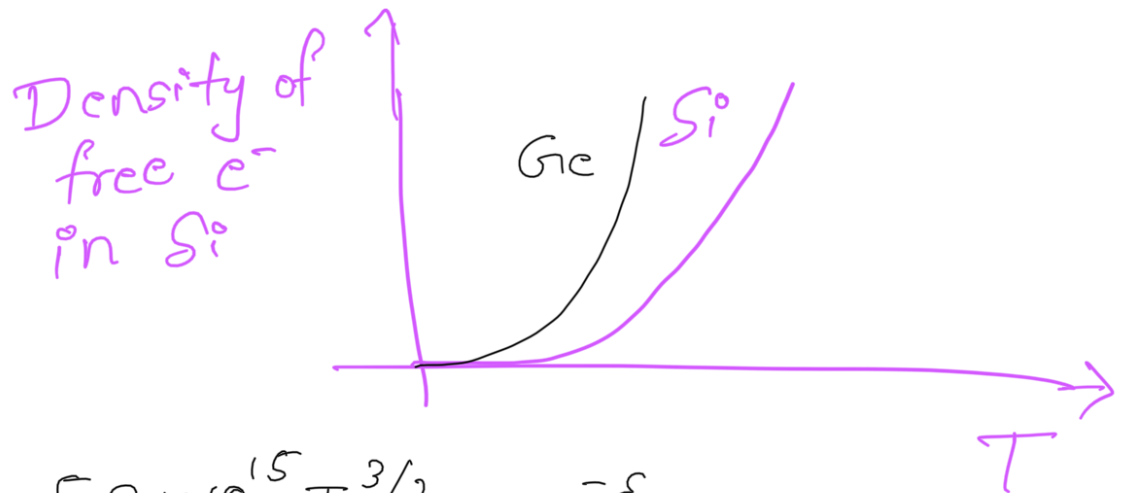


Questions:

- ① Where do charge carriers come from?
- ② What types of charge carriers do we have?
- ③ How can we modify density of charge carriers?

④ How do charge carriers move?

* Concept of bandgap energy:



$$n_i = 5.2 \times 10^{15} T^{3/2} \exp \frac{-E_g}{2kT}$$

Intrinsic Silicon

Boltzmann's Const.
 $1.38 \times 10^{-23} \text{ J/K}$

Bandgap energy

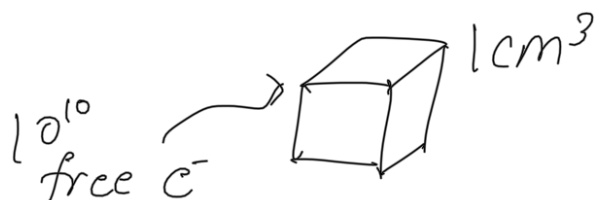
$$E_g : 1.12 \text{ eV} \rightarrow Si$$

$$0.67 \text{ eV} \rightarrow Ge$$

$$2.5 \text{ eV} \rightarrow \text{Diamond}$$

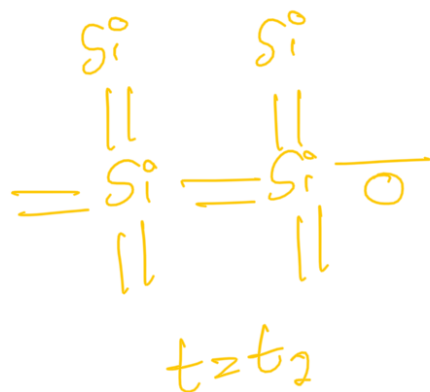
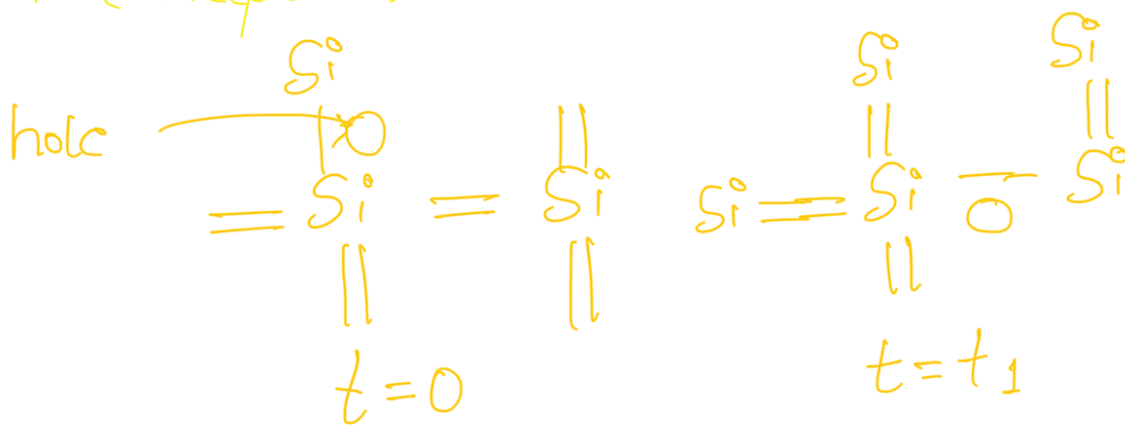
Example : For Si , at $T = 300K$,

$$n_i \approx 10^{10} \text{ electrons/cm}^3$$



5×10^{22} Si atoms/cm³ in which only 10^{10} free e^- because of thermal energy.
(poor conductor) [pure Silicon aka intrinsic Si]

* Concept of holes:



$+ve$ charge travelled from left to right here

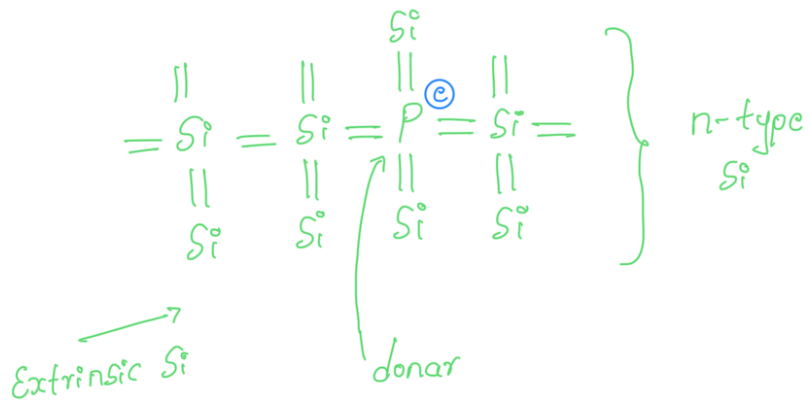
Question: Why are holes slower than electrons?
Movement of holes is based on release and trap mechanisms.

$$\begin{aligned} \text{Density of holes} &= \text{Density of Electrons} = n_i \quad (\text{for pure Si}) \\ p &= n = n_i \\ pn &= n_i^2 \end{aligned}$$

Doping

III | IV | V

Boron (B)		
	Si	Phosphorous (P)
	Ge	



$N_d = \text{Density of P atoms} \approx 10^{15} - 10^{17} / \text{cm}^3$

$n \approx \text{Density of P atoms} \approx N_d$

$np = n_i^2 \quad (\because p \text{ goes down})$